

<i>Notice of References Cited</i>		Application No. <b>09/722,760</b>	Applicant(s) <b>MICHAEL <i>et al</i></b>	
		Examiner <b>J. DOTE</b>	Group Art Unit <b>1756</b>	Page <b>1</b> of <b>1</b>

  

U.S. PATENT DOCUMENTS						
☆	A	DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS
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FOREIGN PATENT DOCUMENTS							
☆	N	DOCUMENT NO.	DATE	COUNTRY	NAME	CLASS	SUBCLASS
	N	<b>55-166652</b>	<b>12/25/80</b>	<b>JAPAN</b>	—		
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NON-PATENT DOCUMENTS		
☆	DOCUMENT (Including Author, Title, Source, and Pertinent Pages)	DATE
	<b>U</b> GRANT, R. <i>et al.</i> ed. GRANT & HACKH'S CHEMICAL DICTIONARY, FIFTH EDITION, MCGRAW-HILL BOOK CO., NY (1987), pp. 22, 23, 71, 321, and 434	<b>1987</b>
	<b>V</b> AMERICAL CHEMICAL SOCIETY (ACS) FILE REGISTRY NO. RN 1332-58-7, COPYRIGHT 2002	<b>2002</b>
	<b>W</b> JAPANESE PATENT OFFICE ENGLISH-LANGUAGE ABSTRACT of JP 55-166652 (pub 12/25/80)	<b>12/80</b>
	<b>X</b>	

\* A copy of this reference is not being furnished with this Office action.  
 (See Manual of Patent Examining Procedure, Section 707.05(a).)